

Confirmation No. 6408

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:	Meunier-Beillard <i>et al.</i>	Examiner:	Khiem Nguyen
Serial No.:	10/550,853	Group Art Unit:	2823
Filed:	September 22, 2005	Docket No.:	NL030357 US1
Title:	METHOD OF EPITAXIAL DEPOSITION OF AN N-DOPED SILICON LAYER		

OFFICE ACTION RESPONSE

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Customer No. 65913

Dear Sir:

In response to the non-final Office Action dated October 28, 2008, please reconsider the application in view of the following amendments and remarks.

A complete listing of the Claims and the Remarks/Arguments follow.

Authorization is provided to charge/credit Deposit Account 50-0996 (NXPS.265PA) any requisite fees/overages to enter this paper.